## AMENDMENTS TO THE SPECIFICATION

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## IN THE SPECIFICATION:

Please amended paragraph 0007 bridging pages 4 and 5 as follows:

[0007] Thus, the present invention is directed to a siloxane-based resin that is prepared by hydrolyzing and polycondensing a first monomer of the formula (1) and a second monomer of the formula (2) in an organic solvent in the presence of an acid or alkaline catalyst and water:

$$\begin{array}{c|c}
R_1 \\
\hline
Si \\
CH_2(CH_2)_mSiX_1X_2X_3
\end{array}$$
(1)

wherein,

 $R_1$  is H,  $C_{1-3}$  alkyl or  $C_{6-15}$  aryl;

each of  $X_1$ ,  $X_2$  and  $X_3$ , independently, is  $C_{1-3}$  alkyl,  $C_{1-10}$  alkoxy or [[halo]] halogen, provided that at least one of them is hydrolysable;

m is an integer from 0 to 10; and

p is an integer from 3 to 8; and

$$X_{i} - \sum_{j=1}^{R_{2}} - 0 = \begin{bmatrix} R_{2} \\ J \\ S_{i} - 0 \\ J \\ R_{2} \end{bmatrix} = \begin{bmatrix} R_{2} \\ J \\ S_{i} - X_{i} \\ J \\ Y_{1} \end{bmatrix}$$
(2)

wherein,

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 $R_2$  is H,  $C_{1-3}$  alkyl or  $C_{6-15}$  aryl;

 $X_4$  is  $C_{1-10}$  alkoxy;

 $Y_1$  is  $C_{1-3}$  alkyl or  $C_{1-10}$  alkoxy; and

n is an integer from 0 to 10.

Please amended paragraph 0013 bridging pages 7 and 8 as follows:

**[0013]** Preferable acids or base catalysts for the preparation of the inventive siloxane-based resin can be exemplified by, but are [[mot]] <u>not</u> limited to, hydrochloric acid, nitric acid, benzene sulfonic acid, oxalic acid, formic acid, potassium hydroxide, sodium hydroxide, triethylamine, sodium bicarbonate and pyridine. Such a catalyst is used so that molar ratio of the catalyst to the monomers is 0.000001:1 - 10:1.

Please amend paragraph 0015 starting at page 8, line 8, as follows:

[0015] Non-limiting examples of organic solvent used in the preparation of the inventive siloxane-based resin include aliphatic hydrocarbon solvents such as hexane; aromatic hydrocarbon solvents such as anisole, mesitylene and xylene; ketone-based solvents such as methyl isobutyl ketone, 1-methyl-2 pyrrolidinone 1-methyl-2-pyrrolidone and acetone; ether-based solvents such as cyclohexanone, tetrahydrofuran and isopropyl ether; acetate-based solvents such as ethyl acetate, butyl acetate and propylene glycol methyl ether acetate; alcohol-based solvents such as isopropyl alcohol and butyl alcohol; amide-based solvents such as

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dimethylacetamide and dimethylformamide; silicon-based solvents; and mixtures thereof.

Please amend paragraph 0021 starting at page 11, line 2, as follows:

[0021] Preferred organic solvents for the dissolution of the siloxane-based resin or the porogen to provide a liquid coating composition can be exemplified by, but are not limited to, aliphatic hydrocarbon solvents such as hexane; aromatic hydrocarbon solvents such as anisole, mesitylene and xylene; ketone-based solvents such as methyl isobutyl ketone, 1-methyl-2-pyrrolidinone 1-methyl-2-pyrrolidone and acetone; ether-based solvents such as cyclohexanone, tetrahydrofuran and isopropyl ether; acetate-based solvents such as ethyl acetate, butyl acetate and propylene glycol methyl ether acetate; alcohol-based solvents such as dimethylacetamide and dimethylformamide; silicon-based solvents; and mixtures thereof.

Please amend paragraph 0032 starting at page 17, line 5 as follows:

[0032] The eyelie linear siloxane monomer (E) was obtained from Sigma Aldrich(U.S.A.).